

Surface Structure of the Liquid $\text{Au}_{72}\text{Ge}_{28}$ Eutectic Phase: X-ray Reflectivity

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The surface structure of the liquid phase of the $\text{Au}_{72}\text{Ge}_{28}$ eutectic alloy has been measured using resonant and non-resonant X-ray Reflectivity and Grazing Incidence X-ray Diffraction. In spite of the significant differences in the surface tension of liquid Ge and Au the Gibbs adsorption enhancement of Ge concentration at the surface is minimal. This is in striking contrast to all the other binary alloys with large differences in the respective surface tensions measured up to date. In addition there is no evidence of the anomalous strong surface layering or in-plane crystalline order that has been reported for the otherwise quite similar liquid $\text{Au}_{82}\text{Si}_{18}$ eutectic. Instead, the surface of eutectic $\text{Au}_{72}\text{Ge}_{28}$ is liquid-like and the layering can be explained by the distorted crystal model with only slight modifications to the first layer.

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I. INTRODUCTION

The surface structure of liquid metals was essentially an unexplored phenomena until slightly more than a decade ago when the first synchrotron X-ray reflectivity studies on liquid metal surfaces were carried out.^{1,2} These measurements on liquid Hg^1 and Ga^2 confirmed the proposal by Rice and colleagues³⁻⁵ that the local order at the free surface was sufficient to induce atomic layering. This layering decays within a distance from the surface of the order of the bulk liquid correlation length, i.e. 3-4 atomic layers.^{4,5} The layering is observed as a peak in the specular reflectivity at the wavevector transfer vector $q_z = 2\pi/d$ where d is the layering distance. Subsequent studies on liquid In^6 , K^7 , Sn^8 and Bi^9 revealed a similar type of layering at the surface of these liquids, demonstrating that this phenomena appears to be universal for metallic liquids, regardless of the surface tension, i.e. $\gamma = 110$ mN/m for K, 560 mN/m for Sn and 770 mN/m for Ga.

Furthermore, similar studies that have been carried out on various liquid metal alloys; i.e. $\text{In}_{78}\text{Bi}_{22}$ ¹⁰, $\text{Sn}_{57}\text{Bi}_{43}$ ¹¹ as well as on Ga- or Hg-based dilute alloys $\text{Ga-Bi}^{12,13}$, Ga-Pb^{14} , Ga-Tl^{15} , Hg-Au^{16} have all demonstrated Gibbs adsorption effects by which the top surface layer is enriched in the respective element with the lower surface tension. The only exceptions for which Gibbs adsorption have not been observed are the alloys of otherwise very

similar elements, i.e. $\text{K}_{67}\text{Na}_{33}$ ¹⁷ and Ga-In^{18} . Although for all these alloys the surface enriched layer in principle is liquid-like, Rice observed that on approaching the liquidus coexistence line the fluid like monolayers of both Tl and Pb at the surface of the Ga-rich Ga-Pb¹⁴ and Ga-Tl¹⁵ alloys form 2D crystals with a lattice structure that is different from that of the bulk phase.

The surface order that appears over a wider range of temperatures above the eutectic temperature of the $\text{Au}_{82}\text{Si}_{18}$ eutectic is yet a very different phenomenon.^{19,20} The first, and most amazing empirical effect for the $\text{Au}_{82}\text{Si}_{18}$ liquid is the anomalously strong surface layering that is revealed by a reflectivity peak which is more than an order of magnitude more intense than for any of the other metals or alloys that have been studied. Furthermore grazing incidence diffraction studies demonstrated that the anomalously strong reflectivity is accompanied by a 2D crystalline bilayer surface phase²¹ with an in-plane rectangular (AuSi_2) unit-cell structure. On heating about 12K above the melting temperature this anomalously strong reflectivity decreases via a first order transition to a weaker, but still enhanced reflectivity and the bilayer structure transforms into a 2D crystalline monolayer. The effect is reversible on cooling. There are no known stable intermetallic Au-Si phases that resemble the lattice constants for the 2D AuSi_2 phase; however, there are similarities to phases that have been observed in thin metastable solid Au-Si

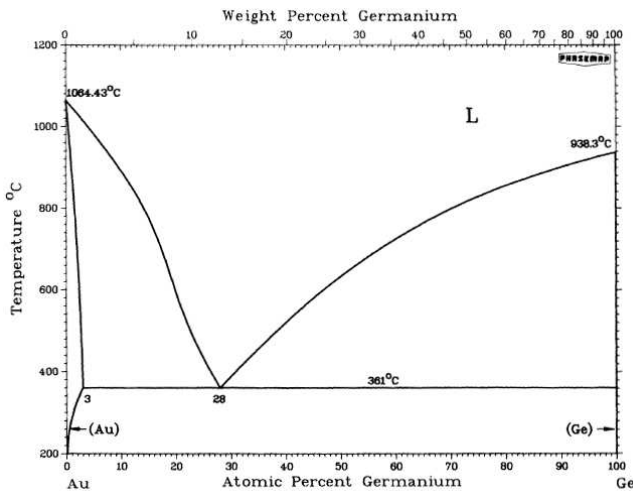


FIG. 1: Phase diagram of Au-Ge²⁷ showing a simple eutectic at a composition at Au₇₂Ge₂₈ and a low eutectic temperature of 634 K as it is also known for the Au-Si system. With permission from author.

films^{22–24}.

At the present time there is no theoretical explanation for the Au-Si surface effect; however, it is reasonable to speculate that it might arise from the relatively strong covalency between Au and Si. In the absence of reliable theoretical guidance it is natural to ask whether the Au-Ge system exhibits a surface structure that is similar to that found in Au-Si. As shown in Fig. 1 the phase diagram of Au-Ge exhibits a deep eutectic that is similar to the Au-Si system and with a eutectic temperature that is essentially the same. Just as in Au-Si there are no known stable intermetallic phases and the solubility of Ge in Au and vice versa in the solid state is low. Aside from the fact that Au-Ge²⁵ does not form the same kind of amorphous phase on rapid quenching of the liquid phase as Au-Si²⁶ the two systems seem otherwise alike.

We report experiments here that reveal that the surface order of the liquid Au₇₂Ge₂₈ eutectic shows no evidence of the anomalous surface induced order that has been observed for the Au₈₂Si₁₈ eutectic. Furthermore, there is no evidence for Gibbs adsorption found in other binary liquid metal alloys with such dissimilar components.

II. BACKGROUND

The kinematics of X-ray scattering from liquid surfaces has been discussed in a number of recent papers.^{7,28–30} X-rays of wavelength λ are incident on the xy-plane of the liquid surface at an angle α . The scattered radiation is detected by a rectangular slit of horizontal and vertical widths ($h \times w$) at a distance L from the sample. The detector slit is located at an angle β to the xy-surface in a plane that makes an angle θ to the plane of incidence.

For a typical modern synchrotron X-ray reflectivity experiment, we can neglect the X-ray beam divergence, the energy resolution, and the width of the incident beam in respect to the size of the detector slits. The angular resolution are $\Delta\theta = w/L$ and $\Delta\beta = (h/L)\cos\beta$. The three components of the wave vector transfer for radiation striking the center of the detector are:

$$\begin{aligned} q_x &= (2\pi/\lambda)\cos\beta\sin\theta \\ q_y &= -(2\pi/\lambda)(\cos\alpha - \cos\beta\cos\theta) \\ q_z &= (2\pi/\lambda)(\sin\alpha + \sin\beta) \end{aligned} \quad (1)$$

It has been shown^{7,31} that the equation which describes the specular reflectivity from a liquid metal surface can be broken up into three terms:

$$R(q_z) = R_F(q_z) \times CW(q_z) \times |\Phi(q_z)|^2 \quad (2)$$

The first term, R_F , is the theoretical Fresnel X-ray reflectivity from an abrupt flat interface between vacuum and the bulk. For $q_z \gg q_c$ (≈ 5 times larger) $R_F(q_z)$ has the simple form of:

$$R_F(q_z) \approx \left(\frac{q_c}{2q_z}\right)^4. \quad (3)$$

For an incident angle α which corresponds to q_z smaller than the critical wave vector q_c the X-rays are fully reflected. We have used a more complete expression for $R_F(q_z)$ that also includes X-ray absorption but the results are indistinguishable. The critical wave vector q_c is given by $q_c = 4\sqrt{\rho_\infty r_0 \pi}$ where ρ_∞ is the effective bulk electron density, which includes the resonant reduction in scattering amplitude, and r_0 is the classical electron radius of 2.818×10^{-5} Å. When presenting reflectivity data, which typically ranges over ~ 10 orders of magnitude, it is convenient to divide the data by $R_F(q_z)$.

The second term in equation 2, $CW(q_z)$, is a Debye-Waller like factor due to thermally excited capillary waves, which depends on the temperature, T , and the surface tension, γ .

$$CW(q_z) = \int_{A_{q_{xy}}} d^2 q_{xy} \left(\frac{q_{xy}}{q_{max}}\right)^\eta \frac{\eta}{2\pi q_{xy}} \quad (4)$$

where $\eta = \frac{k_B T}{2\pi\gamma} q_z^2$, q_{max} is the cut-off wavevector of the system (here 1.45 \AA^{-1}) and $A_{q_{xy}}$ is the projection of the detector slit in q-space³². Note that the value of the integral depends on the experimental resolution. The acceptance angle of the detector slit is: $\Omega = \Delta\theta \times \Delta\beta \times \cos(\beta)$.

Dividing the experimental data by both $R_F(q_z)$, (which only depends on the bulk electron density) and $CW(q_z)$ (which is accurately known from capillary wave theory) one obtains the surface structure factor which $\Phi(q_z)$. $\Phi(q_z)$ itself only depends on the electron density profile along the surface normal.

$$\Phi(q_z) = \frac{1}{\rho_\infty} \int dz \frac{d\langle\rho(z)\rangle}{dz} \exp[iq_z z] \quad (5)$$

Here $\langle \rho(z) \rangle$ denotes the surface parallel average of the surface electron density at a position z along the normal to the surface and ρ_∞ is the electron density in the bulk liquid. The electron density $\langle \rho(z) \rangle$ is generally obtained by numerical fitting of the measured reflectivity, $R(q_z)$, divided by $R_F(q_z)$ and $CW(q_z)$ with the physical model described below.

A simple but very useful model for the electron density in liquid metals is derived from a version of the Distorted Crystal Model (DCM)¹, in which the ratio of the average atomic density at some position z along the surface normal in the bulk liquid is described by a sum of Gaussian functions separated by a distance, d :

$$\frac{\langle \rho_{DCM}^a(z) \rangle}{\rho_\infty^a} = \sum_{n=0}^{\infty} \frac{d}{\sigma_n \sqrt{2\pi}} \exp \left[-\frac{(z - nd)^2}{2\sigma_n^2} \right] \quad (6)$$

In this model the width of the Gaussian functions increases with the distance from the surface, $\sigma_n^2 = \sigma_0^2 + n\bar{\sigma}^2$. As the distance from the surface increases the model approaches a uniform function whose value is just unity. The superscript a refers to atomic densities. Substitution (of $\langle \rho_{DCM}^a(z) \rangle / \rho_\infty^a$) into Eq. 5 obtains the very convenient analytic expression for the atomic analogue of the structure factor.

$$\begin{aligned} \Phi_{DCM}^a(q_z) &= iq_z d \sum_{n=0}^{\infty} \exp[iq_z dn] \exp[-q_z^2 \sigma_n^2 / 2] \\ &= iq_z d \frac{\exp[-\sigma_0^2 q_z^2 / 2]}{1 - \exp[iq_z d] \exp[\bar{\sigma}^2 q_z^2 / 2]} \end{aligned} \quad (7)$$

Despite having only 3 parameters the surface structure factor that is obtained by convolution of $\Phi_{DCM}^a(q_z)$ with the atomic form factors describe the reflectivity from Ga, In, and K exceptionally well. The surface structure of others, like Sn and Bi can only be described with slight modifications of the DCM and we will show below that similar modifications of the DCM are necessary for Au₇₂Ge₂₈.

The simplest atomic density model that will adequately describe the Au-Ge data requires modification of the topmost atomic layer at the liquid/vapor surface. Although this can be done in different ways the most convenient is to supplement the DCM by addition of an ad-layer between the vapor and the DCM. The atomic distribution of this layer can be described by three additional parameters: its integrated density N_A , its position P_A and width σ_A ;

$$\frac{\langle \rho_A^a(z) \rangle}{\rho_\infty^a} = \frac{N_A d}{\sigma_A \sqrt{2\pi}} \exp \left[-\frac{(z - P_A)^2}{2\sigma_A^2} \right] \quad (8)$$

where the factor N_A , which specifies the integrated atomic density of the ad-layer, is expressed in terms of the atomic volumes (V_{Ge} , V_{Au}) of Ge and Au and their surface and bulk concentrations (X_A and X_∞):

$$N_A = \frac{X_\infty V_{Au} + (1 - X_\infty) V_{Ge}}{X_A V_{Au} + (1 - X_A) V_{Ge}}. \quad (9)$$

The resulting bulk normalized electron density has the form:

$$\begin{aligned} \frac{\langle \rho(z) \rangle}{\rho_\infty} &= \frac{\langle \rho_A^a(z) \rangle}{\rho_\infty^a} \otimes \frac{X_A F_{Au}(z) + (1 - X_A) F_{Ge}(z)}{X_\infty Z_{Au} + (1 - X_\infty) Z_{Ge}} \\ &+ \frac{\langle \rho_{DCM}^a(z) \rangle}{\rho_\infty^a} \otimes \frac{X_\infty F_{Au}(z) + (1 - X_\infty) F_{Ge}(z)}{X_\infty Z_{Au} + (1 - X_\infty) Z_{Ge}} \end{aligned} \quad (10)$$

where \otimes denotes convolution and $F_{Au}(z)$ and $F_{Ge}(z)$ is the xy-integral of the atomic electron density distributions for Au and Ge respectively. If the energy dispersive effects are neglected, atomic form factors $f(q_z)$ are just the Fourier transforms of the electron densities, $f(q_z) = \int dz F(z) \exp[iq_z z]$ (note that $f(0) = Z$). As a practical matter we use tabulated values of the form factor³³. If energy dispersive effects were negligible the surface structure factor could be modeled by substitution of Eq. 10 into Eq. 5

$$\begin{aligned} \Phi(q_z) &= \Phi_A^a(q_z) \frac{X_A f_{Au}(q_z) + (1 - X_A) f_{Ge}(q_z)}{X_\infty f_{Au}(0) + (1 - X_\infty) f_{Ge}(0)} \\ &+ \Phi_{DCM}^a(q_z) \frac{X_\infty f_{Au}(q_z) + (1 - X_\infty) f_{Ge}(q_z)}{X_\infty f_{Au}(0) + (1 - X_\infty) f_{Ge}(0)}. \end{aligned} \quad (11)$$

The contribution from the DCM, $\Phi_{DCM}^a(q_z)$, is given in Eq. 7 and the contribution from the ad-layer $\Phi_A^a(q_z)$ is:

$$\Phi_A^a(q_z) = iq_z N_A d \exp[iq_z P_A] \exp[-q_z^2 \sigma_A^2 / 2] \quad (12)$$

The effect of energy dispersion can be taken into account by recognizing that for near forward scattering the effective number of electrons for a Z-electron atom varies as $Z_{eff} = Z + f'_{q_z=0}(E)$ where $f'_{q_z=0}(E)$ is the energy dependent correction to the atomic scattering amplitude³⁴.

The effect that is used here to probe the difference between the Ge surface and bulk concentrations is based on the fact that close to an absorption edge $f'_{q_z=0}(E)$ becomes a significant negative number. For an alloy the energy dependent change in contrast between surface and bulk can be used to determine if surface segregation occurs. We approximate the energy dependent form factor $f(q_z, E)$ as:

$$f(q_z, E) = f(q_z) \frac{Z + f'_{q_z=0}(E)}{Z} \quad (13)$$

where tabulated values are used for the energy dependent correction $f'_{q_z=0}(E)$ ³⁴. The compound form factor for an Au_XGe_{1-X} alloy is not known and as a practical matter we approximate the total expression for $\Phi(q_z, E)$ in our model as:

$$\begin{aligned} \Phi(q_z, E) &= \Phi_A^a(q_z) \frac{X_A f_{Au}(q_z, E) + (1 - X_A) f_{Ge}(q_z, E)}{X_\infty f_{Au}(0, E) + (1 - X_\infty) f_{Ge}(0, E)} \\ &+ \Phi_{DCM}^a(q_z) \frac{X_\infty f_{Au}(q_z, E) + (1 - X_\infty) f_{Ge}(q_z, E)}{X_\infty f_{Au}(0, E) + (1 - X_\infty) f_{Ge}(0, E)} \end{aligned} \quad (14)$$

This model has adjustable 6 parameters (d , σ_0 , $\bar{\sigma}$, P_A , σ_A and X_A). The first three parameters: d , σ_0 and $\bar{\sigma}$ give the DCM part of the model, where d is the distance between layers, σ_0 is the width of the first layer, and the $\bar{\sigma}$ parameter determine the increase in width for subsequent layers. The surface structure factor obtained with only the DCM model, $|\Phi_{DCM}^a(q_z)|^2$ is a monotonic increasing function from unity at $q_z = 0$ to a peak located at $\sim 2\pi/d$. The peak width is determined by $\bar{\sigma}$ and its height originates from both σ_0 and $\bar{\sigma}$.

The last three parameters refers to the ad-layer: σ_A , P_A and X_A define the width, the position and the atomic Au concentration. These parameters can be chosen so that the adlayer becomes a part of the DCM, i.e. $\sigma_A = \sqrt{\sigma_0^2 - \bar{\sigma}^2}$, $P_A = -d$ and $X_A = X_\infty$. If the parameters depart from this values the interference between the layers in the model is altered and the structure factor can exhibit structure that deviates from the monotonically increasing behaviour of the DCM⁹.

The effective bulk electron density ρ_∞ that we later use to set the critical angle for total reflection, q_c , of the liquid Au-Ge sample is given by:

$$\rho_\infty = \frac{X_\infty(Z_{Au} + f'_{Au}(E)) + (1 - X_\infty)(Z_{Ge} + f'_{Ge}(E))}{X_\infty V_{Au} + (1 - X_\infty)V_{Ge}} \quad (15)$$

An alternative way to construct a model with a DCM plus one layer would be to substitute/exchange the outermost layer in the DCM model instead of adding another layer. If $\sigma_{-1} < \sigma_0$ it is easy to show that by adjusting σ_0 this model can be made equivalent to the ad-layer model.

III. EXPERIMENTAL

The Au-Ge sample material was obtained from Goodfellow Inc. as commercially available high purity Au₇₂Ge₂₈ eutectic alloy. The alloy was melted inside an ultra high vacuum x-ray chamber in a molybdenum pan that is heated by an boraelectric heater from the bottom side. A K-type thermocouple was directly mounted to the side of the molybdenum pan to measure the temperature of the sample.

After initial melting of the alloy some germanium oxide patches remained on the surfaces. These have been removed at first by mechanically scraping/wiping the surface with a molybdenum scraper. Remaining oxide particles were then eliminated from the surface by Ar⁺ ion beam sputtering at 5 keV for several hours. The liquid surface then was free of any visible oxide. Further proof that the surface was clean is the observation that the x-ray reflectivity was unchanged when the beam was translated across the sample. The sample was kept at a temperature of about 15-20 K above the eutectic temperature of 637K. During reflectivity measurements the vacuum was in the 10⁻⁹ mbar range.

The X-ray measurements have been performed using

	11.05 keV	11.915 keV	12.00 keV
$f'_{Ge}(E)$	-4.8	-1.7	-1.6
$f'_{Au}(E)$	-7.5	-17.6	-12.0

TABLE I: Dispersive corrections to the atomic scattering amplitudes $f'_{q_z=0}(E)$ for Au and Ge at different x-ray energies, used to model the measured reflectivities using Eq. 14.

the liquid reflectometer at the beamline ID-15 at ChemMatCARS, Advanced Photon Source at Argonne National Laboratory. X-ray reflectivity (XR) studies were carried out at 11.050 keV, i.e. slightly below the K-absorption edge of Ge at 11.103 keV, at 11.915 keV that is slightly below the L3-absorption edge of Au at 11.919 keV, as well as at 12.000 keV. The corresponding corrections to the atomic scattering amplitudes used to analyze the reflectivity data are summarized in table I. The atomic scattering amplitudes were taken from analytical approximation to the scattering factor tables in³⁴

For the reflectivity studies vertical soller slits were mounted in front of the scintillation counter point detector. The horizontal angular resolution of the soller slits is 2.0 mrad. Additionally a vertical slit of 6 mm height in a distance of 685 mm from the sample gives a vertical resolution of 7.0 mrad. Complementary grazing incidence x-ray diffraction (GIXRD) have been performed using the soller slits with the same angular resolution, but the vertical slits were set to 10 mm.

Although the critical angle for total reflection, q_c , of the liquid Au-Ge sample could not be measured reliably due to a rather small curvature of the liquid sample of about 1200 mm the value of q_c could be calculated from the effective electron density of the Au-Ge liquid, ρ , by equation I using the equation for q_c that was given following equation 3. The atomic volumes V_{Au} and V_{Ge} were calculated by a hexagonal close packed sphere approximation using the covalent radius of Au (1.44 Å) and Ge (1.22 Å). The values of q_c were found to be 0.0745 Å⁻¹, 0.0703 Å⁻¹ and 0.073 Å⁻¹ for x-ray energies of 11.05 keV, 11.915 keV and 12.00 keV, respectively. By a similar calculation for Au₈₂Si₁₈, for which q_c is precisely known²¹, we estimated the error for this method to be around 4%.

IV. RESULTS

The measured reflectivity curves for liquid Au₇₂Ge₂₈ taken at a sample temperature at 653 K, i.e. 20 K above the eutectic temperature and at x-ray energies of 11.05 keV, 11.915 keV and 12.00 keV are shown in Fig. 2a. The solid line in the figure illustrates the theoretical $R_F(q_z)$ for the data taken at 11.05 keV, for which $q_c=0.0745$ Å⁻¹. In view of the fact that the R_F curves of the other energies only differ by less than $\sim 2.5\%$ they would be indistinguishable from each other on this plot. Clearly, the reflectivity data measured at different energies do not dif-

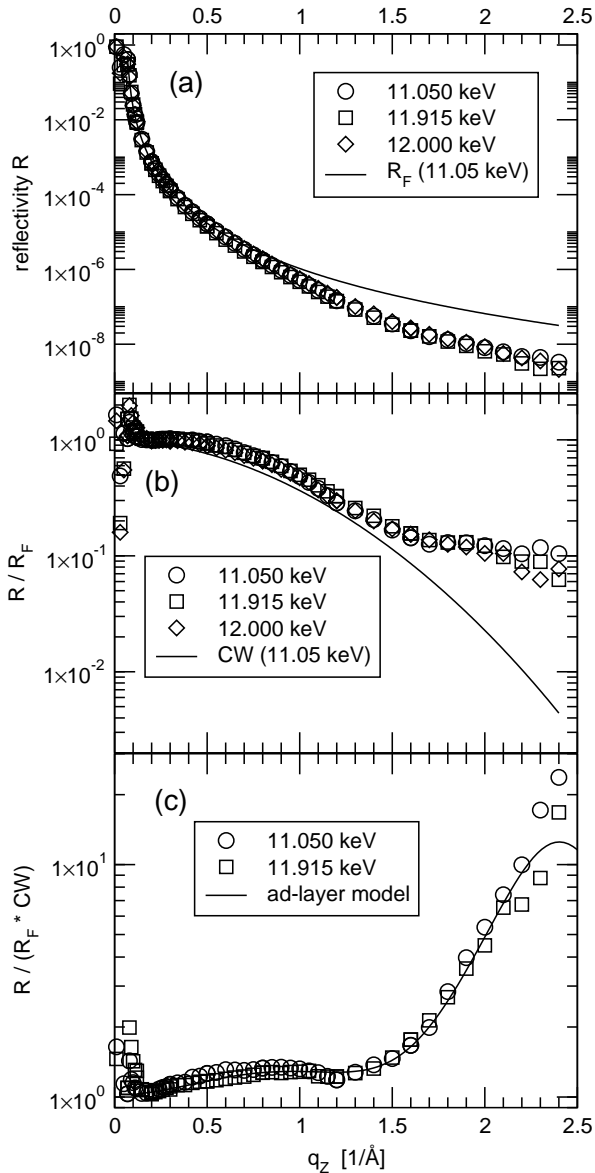


FIG. 2: (a) X-ray reflectivity of eutectic $\text{Au}_{72}\text{Ge}_{28}$ measured at x-ray energies of 11.05 keV, 11.915 keV and 12.00 keV. Additionally the Fresnel reflectivity curve (R_F) is plotted that was obtained by fitting the reflectivity at 11.05 keV in the low q_z range. (b) Reflectivity of liquid $\text{Au}_{72}\text{Ge}_{28}$ after normalization by the respective Fresnel reflectivity, i.e. R/R_F . Added is the contribution of capillary wave function, $CW(q_z)$, to the reflectivity at 11.05 keV. (c) The same data after normalization by the respective R_F and the contribution from capillary waves, CW , i.e. $R/(R_F * CW)$. The solid line represents the best fit to the data using the ad-layer model as given by Eq. 10.

fer significantly from each other at q_z less than 2.2 \AA^{-1} . The differences at larger q_z arise from statistical errors due to the combination of the very low intensity of the reflected beam and the strongly increasing background scattering from the bulk Au-Ge liquid.

In order to better visualize the data the ratio

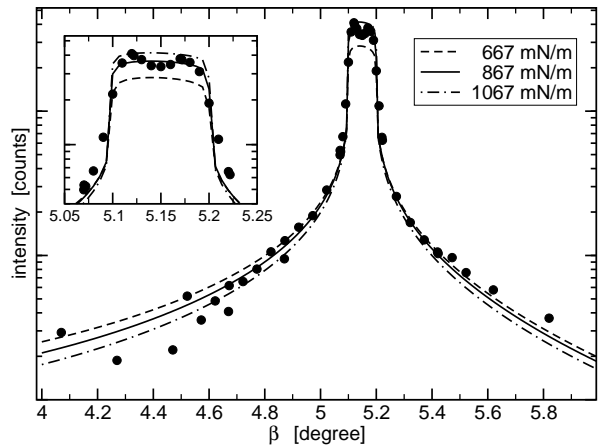


FIG. 3: Off-specular diffuse scattering measured with a x-ray energy of 11.05 keV at incidence angle, α , of 5.15 degree. The dots, \bullet , represent data points and the lines represent calculated off-specular diffuse scattering for different surface tensions. The solid line ($\gamma = 867 \text{ mN/m}$) shows the best fit. The broken lines at $\pm 200 \text{ mN/m}$ are included to give an idea about the sensitivity of fitted parameter γ .

$R(q_z)/R_F(q_z)$ for the different energies is shown in Fig. 2b. Here the shape of the reflectivities, i.e. the noticeable increase in slope around $q_z = 1.7 \text{ \AA}^{-1}$ is clear proof of surface layering^{7,35} of the $\text{Au}_{72}\text{Ge}_{28}$ liquid. Added in the figure is the theoretical form for $CW(q_z)$ which itself is a known function of the surface tension. As discussed elsewhere^{6-8,35} the surface tension can be determined from the off-specular diffuse scattering as it is shown in Fig. 3 for the Au-Ge liquid measured with a x-ray energy of 11.05 keV at incidence angle, α , of 5.15 degree that corresponds to $q_z = 1 \text{ \AA}^{-1}$. The algebraic singularity is best measured with the highest possible resolution. On the other hand, if the slit is too small (resolution too high) it would become necessary to account for the angular divergence of the incident beam and the effects of the sample curvature. The diffuse data is best analyzed by choosing a slit height that produces the flat top shown and then comparing the data with the integral of the algebraic singularity over the known resolution. The various lines through the data correspond to different values of the surface tension, γ , used in Eq. 4. The data is best represented by a surface tension of 867 mN/m which is the value obtained by the best NLLS (Non Linear Least Square) fit. The broken lines illustrate calculated diffuse scattering for $\eta = 667 \text{ mN/m}$ and 1067 mN/m and are included to give an idea about the sensitivity of γ as fitted parameter. We determine the surface tension to be $867 \pm 100 \text{ mN/m}$ and we use the value 867 mN/m in calculating the $CW(q_z)$, that is plotted as the solid line in Fig. 2b.

Fig. 2c shows the experimental data obtained at 11.050 keV and 11.915 keV after division with $R_F(q_z)$ and $CW(q_z)$. This data can now be compared directly with the surface structure factor, $|\Phi(q_z)|^2$. The data exhibits

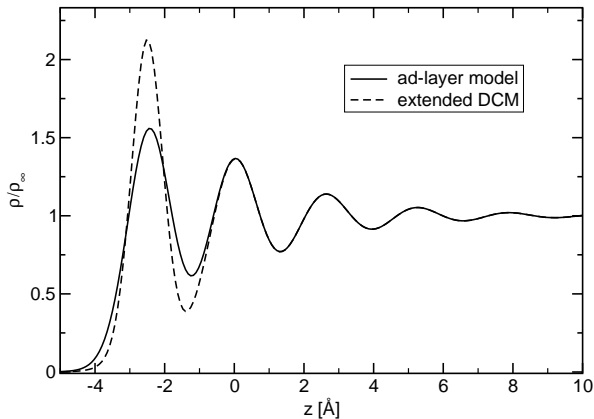


FIG. 4: The solid red line denotes the electron density profile of the best fit using the ad-layer model. The broken line shows the electron density profile then the DCM are extended to the ad-layer.

two prominent features. The first is the broad maximum centered around $q_z=0.8 \text{ \AA}^{-1}$. The second is the steep rise for q_z higher than 1.5 \AA^{-1} that originates from surface layering^{7,35}. On the other hand, because of the first broad first maximum (or in other words the occurrence of the minimum at around $q_z=1.2 \text{ \AA}^{-1}$) slight modifications to the first layer are needed, as the DCM produces a monotonically increasing structure factor in this range.

Although a similar effect, i.e. a local minimum in the surface structure factor was also observed for elemental Sn⁸ and Bi⁹ the origin in this binary alloy can be different since here in Au-Ge there is the possibility that as a consequence of Gibbs adsorption the chemical composition of the first layer(s) could be different from the bulk^{11,30,36}. The fact that the structure factor data at 11.915 keV and 11.05 keV are virtually identical would seem to imply that this is not the case, nevertheless, the following analysis is directed towards just this issue. To account for the minimum in the structure factor the electron density model has to be adjusted in a similar manner as it was necessary for the surface of liquid Sn⁸ and Bi⁹ by introduction of a top surface ad-layer with a width and a distance to the next layer that is different from requirements of the DCM.

The solid line in Fig. 2c displays the result of a simultaneous fit of both the 11.05 keV and 11.915 keV experimental data to the respective surface structure factor using the ad-layer model given by Eq. 14 and a surface concentration of Ge ($1-X_A$) of 28 at.-% that is identical to the bulk value. The energy dispersion was accounted for using the values for the dispersive corrections to the real part of the atomic scattering amplitudes that are given in Table I. In view of the fact that the surface structure factor is independent of energy the concentrations in the ad-layer and bulk are the same. Although the critical angle is energy dependent this only affects $R_F(q_z)$ that doesn't affect the prediction for $R(q_z)/(R_F(q_z) \times CW(q_z))$ that is represented by the single solid line in Fig. 2c. The model

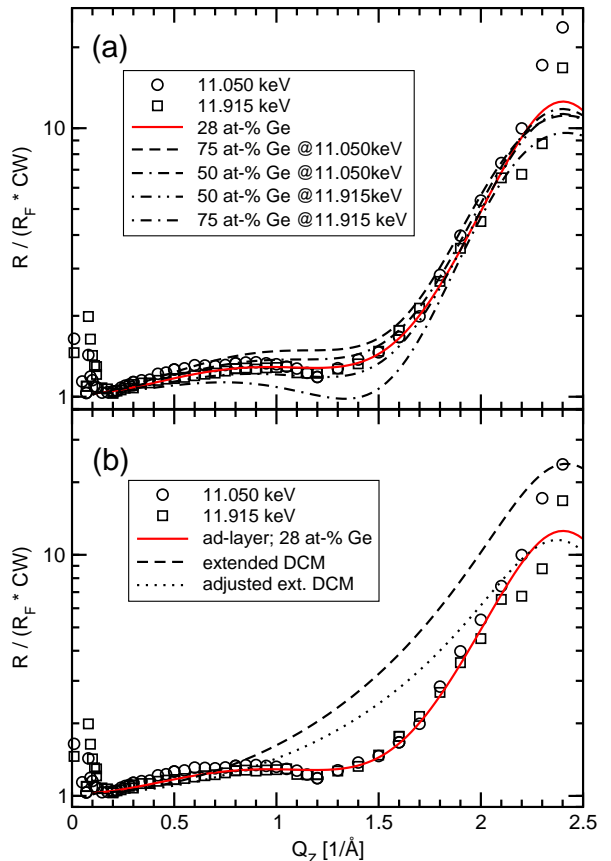


FIG. 5: (a) The lines represents the surface structure factor of liquid Au₇₂Ge₂₈ as calculated for x-ray energies of 11.05 keV and 11.915 keV. The solid red line denotes the best fit to the data using the ad-layer model as given by Eq. 10. Here the Ge concentration in the ad-layer is the same as in the bulk. The broken lines represents theoretical modelling of the surface structure factor using a Ge concentration in the ad-layer different from the bulk. (b) Again the solid red line denotes the best fit to the data using the ad-layer model. The broken line is the structure factor from the electron density shown as a broken line in Fig. 4. The dotted line is obtained by increasing σ_0 from 0.41 \AA to 0.55 \AA to better match the height of the peak.

parameters are given in the first row in Table II and the corresponding electron density profile is represented by the solid line in Fig. 4.

To illustrate the effect of a varying concentration of Ge in the ad-layer, the structure factors for both energies (11.050 and 11.915 keV) were again fitted simultaneously for fixed surface concentrations of Ge of 50 and 75 at.-%, respectively (see Fig. 5(a)). It is evident from these best possible fits that even a modest surface enrichment of Ge to 50 at.-% leads to a spreading of the respective structure factors, which is not represented by the data. The structure factors for 75 at.-% Ge surface concentration are even more different, indicating that indeed the surface enrichment of Ge in Au₇₂Ge₂₈ is not very significant. The parameters for these fits for 50 and 75 at.-% Ge are

	σ_0 [Å]	$\bar{\sigma}$ [Å]	d [Å]	X_A	σ_A [Å]	P_A [Å]
ad-layer(28at-%Ge)	0.71	0.58	2.5	0.72	0.60	-2.43
ad-layer(50at-%Ge)	0.74	0.64	2.5	0.50	0.54	-2.38
ad-layer(75at-%Ge)	0.78	0.75	2.5	0.25	0.46	-2.30
ad-layer($d = 2.4\text{Å}$)	0.67	0.64	2.4	0.72	0.55	-2.35
ad-layer($d = 2.6\text{Å}$)	0.76	0.53	2.6	0.72	0.65	-2.52

TABLE II: Parameters for the ad-layer and DCM models obtained by NLLS fit of the 11.05 keV and 11.915 keV data with Eq. 14. Parameters are explained in the background section. Note that the Ge concentration in the ad-layer is $1 - X_A$.

shown in the second and third row in Table II.

As previously mentioned, because of the minimum centered around $q_z \approx 1.2 \text{ \AA}^{-1}$ it is theoretically impossible to fit the data with only the DCM. One way to demonstrate the inadequacy of the DCM in fitting this data is illustrated by the electron density profile illustrated by the broken line in Fig. 4. This model is constructed by constraining the width, position and amplitude of the ad-layer to be precisely what it would be if the DCM was extended to the surface. As can be seen the effect is that in this model peak amplitude of the first layer is about 1/3 larger than the best fit ad-layer model. The effect on the structure factor is illustrated with the broken line in Fig. 5b. Furthermore, the dotted line in Fig. 5b illustrates the structure factor for a DCM in which the value of σ_0 were chosen (increased) to match the peak amplitude of the structure factor. These traces illustrate that even slight changes in the relation between the first and subsequent layers in the DCM are sufficient to the destroy the subtle interference that gives rise to the monotonically rising low q_z structure factor. In the best fit model the broad low q_z maxima and subsequent minima at $q_z \approx 1.2 \text{ \AA}^{-1}$ were the consequence of slight broadening and shifting of the first layer.

On the other hand, as was seen in other systems^{8,9,19,20} for the modified DCM with the ad-layer the parameters are considerably cross-correlated and it is possible also for $\text{Au}_{72}\text{Ge}_{28}$ to get fits that are essentially as good with a layering spacing parameter, d , that are constrained to be different from 2.5 \AA those in Table II. For example, the last two rows in Table II display the best fit parameters if the layer spacing is constrained to be either 2.4 \AA or 2.6 \AA rather than 2.5 \AA . A significantly larger value, say 2.65 \AA , is unacceptable in that it causes the surface layering peak to move to a value of q_z that is clearly too small. On the other hand values of layer spacing that are much smaller, say 2.35 \AA are not consistent with the close packed spheres with the covalent radius of Au (1.44 \AA).

Although the absence of a strong enhanced peak in the reflectivity does strongly suggest the absence of crystalline 2D surface order like that found for $\text{Au}_{82}\text{Si}_{18}$, the data for the GIXRD measurement shown in Fig. 6 indicates this directly. The GIXRD data were measured at an incidence angle of about 4.1 mrad, that is well below

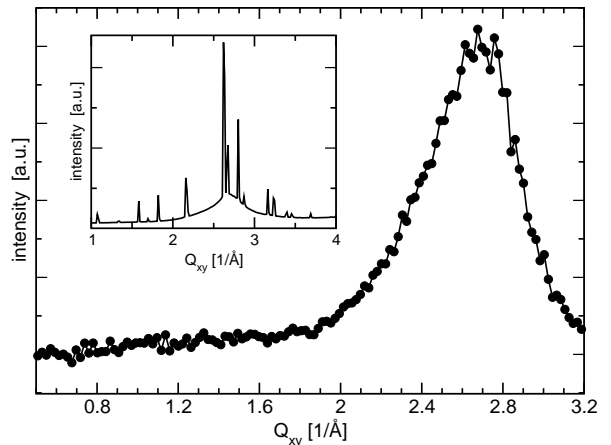


FIG. 6: Grazing incidence x-ray diffractogram of the surface of liquid $\text{Au}_{72}\text{Ge}_{28}$ and $\text{Au}_{82}\text{Si}_{18}$ slightly above the eutectic temperature. The $\text{Au}_{72}\text{Ge}_{28}$ surface does not produce discrete Bragg reflections like those found in the $\text{Au}_{82}\text{Si}_{18}$ liquid (see inset) but only the diffuse diffraction maxima that characterizes a liquid surface.

the critical angle (5.8 mrad). Clearly, there is no sign of sharp Bragg reflections found at the surface of liquid $\text{Au}_{82}\text{Si}_{18}$ eutectic (see inset in Fig. 6). Nevertheless, due to the small radius of curvature of the liquid $\text{Au}_{72}\text{Si}_{28}$ sample it is possible that some portion of the x-rays has a higher incidence angle above the critical angle and should therefore penetrate into the bulk liquid. With the radius of curvature around 1200 mm and with a beam height of the order of 0.02 mm, if the mean incident angle is of the order of $\alpha/2 \approx 0.18^\circ$ the largest incident angle would not be much larger than α and the penetration into the bulk would not be more and a few tens of Angstroms. In view of the fact that the Bragg reflections in liquid $\text{Au}_{82}\text{Si}_{18}$ can also still be detected when the incidence angle is above the critical angle, although with lower intensity relative to the bulk scattering, the absence of observable Bragg peaks for $\text{Au}_{72}\text{Ge}_{28}$ does strongly suggest the absence of 2D crystalline surface order. The broad maximum centered around $q_{xy} = 2.65 \text{ \AA}^{-1}$ that is characteristic of the bulk liquid structure factor is the only feature of this data, indicating that the surface of liquid $\text{Au}_{72}\text{Ge}_{28}$ is liquid-like.

V. DISCUSSION

The principal result from this study is the demonstration that the surface structure of the liquid $\text{Au}_{72}\text{Ge}_{28}$ eutectic does not exhibit the same extraordinary properties that were found recently for liquid eutectic $\text{Au}_{82}\text{Si}_{18}$, i.e. a strong layering normal to the surface that is accompanied by an in-plane 2D crystalline long range order. The liquid phase of Au-Ge only shows a modest, standard-like surface layering that is similar to the majority of the metallic liquids investigated so far. The

	units	Si	Ge
x_{bulk}	[at-%]	18	28
$\Delta H_{mix}(\text{Au-X})$	[kJ/mol]	-30	-21.5
T_m (eutectic)	[K]	637	637
γ	[mN/m]	865	621

TABLE III: Comparison of physical parameters for eutectic Au-Si and Au-Ge alloy. x_{bulk} is the concentration of the respective solute, ΔH_{mix} the atomic mixing enthalpy according to³⁷, T_m the respective eutectic temperatures and γ the surface tension of the pure liquid phase of Si and Ge³⁸

broad low q_z structure of the Au-Ge alloy is qualitatively similar to what was found for elemental Sn and Bi. It is not really clear whether the subtle layer structure of the DCM that predicts smoothly monotonic low q_z growth in the structure factor for Ga, In and K should be more remarkable than the 1st layer deviations that give rise to in the properties of Sn, Bi and Au-Ge. These are clearly issues that call out for theoretical guidance.

From one point of view the difference between Au-Ge and liquid Au-Si is somewhat surprising in that the phase diagram and the physical parameters for Ge and Si are so similar. Their mixing enthalpy with Au, the surface tension of the pure element and the eutectic temperature, that are given in Table III are not dramatically different. The first experimental observation that would appear to correlate with the absence of the surface anomaly for $\text{Au}_{72}\text{Ge}_{28}$ is the measurement of the temperature dependence of ion emissivity from eutectic Au-Ge and Au-Si liquid surfaces.^{39,40} According to these measurements the temperature derivative of the surface tension just above the melting point is positive for the $\text{Au}_{82}\text{Si}_{18}$ and negative for $\text{Au}_{72}\text{Ge}_{28}$. In view of the fact that the sign of the derivative should be determined by the degree of surface order⁴¹ these results imply that the $\text{Au}_{72}\text{Ge}_{28}$ surface should be more disordered than that of $\text{Au}_{82}\text{Si}_{18}$ which is in accordance to the measurements presented here. On the other hand, this belies the point since we do not understand why it should be so.

At some level the difference between the surface properties of liquid $\text{Au}_{82}\text{Si}_{18}$ and $\text{Au}_{72}\text{Ge}_{28}$ probably has to be related to the kind of short range order present in the bulk liquid phase, i.e. to the chemical interactions between Au and Si and on the other hand between Au and Ge. One property that might be important when discussing the origin of crystalline surface phases in metallic liquid alloys is the glass forming ability of the respective

alloy. Interestingly, liquid alloys of Au-Si at composition around the eutectic can be cast into the amorphous phase by rapid quenching technologies²⁶, while for Au-Ge it only produces metastable intermetallic phases²⁵.

It is known that glass forming liquids have a rather high degree of short range order in the liquid as well as in the undercooled liquid^{42,43}. It is possible that the relatively small difference between the enthalpy of mixing, which for Au-Si is approximately 30% larger than for Au-Ge, is sufficient to account for the different properties; however, this would seem surprising. Interestingly, all other liquid metallic binary alloys investigated so far like, for example, Au-Sn, In-Bi, Sn-Bi show a much smaller enthalpy of mixing than both Au-Si and Au-Ge and in some cases the enthalpy of mixing is nearly zero (as is the case for In-Bi and Sn-Bi). In other words the Au-Si resembles the highest value of negative heat of mixing followed by Au-Ge and is the only alloy to show anomalous surface behavior of the liquid phase. Although it is possible that the enhanced Au-Si enthalpy of mixing is an indication of stronger chemical bonding it isn't clear why the $\sim 50\%$ difference should be sufficient to cause the observed differences in the surface properties.

Finally, the absence of Gibbs adsorption at the surface of liquid Au-Ge is also surprising. The simplest interpretation of Gibbs adsorption would lead one to expect the surface enhancement would increase systematically with increasing disparity on solute/solvent surface tension. Although some deviations from these simple expectations might have been expected on the basis of theories such as Guggenheim⁴⁴, Strohl-King⁴⁵ and Defay-Prigogine⁴⁶, the relatively modest differences between the enthalpy of mixing for Au-Si and Au-Ge (Table III) is really too slight to explain the difference in the surface adsorption.

VI. ACKNOWLEDGEMENTS

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